DECLARATION and POWER OF ATTORNEY

Kogyo-7

As a below-named inventor, I declare that I believe that I am the original, first and sole inventor (if only one name is listed below) or an original, first and joint inventor (if plural names are listed below) of the subject matter which is claimed in the specification identified below and for which a patent is sought on the invention as titled therein. I hereby state that I have reviewed and understand the contents of said specification including the claims, as amended by any amendment referred to herein. I acknowledge the duty to disclose to the Office all information known to me to be material to patentability as defined in 37 CFR §1.56.

Full Name

of Inventor (1)

UTSUNOMIYA

Billing

Middle Name

SHIN

Post Office Address City INBA-GUN Full Name of Inventor ⁽²⁾ CHIBA City INBA-GUN First Name SEIGO Residence & City CHIBA CHIBA CHIBA City CHIBA First Name SEIGO State or Foreign Country Country of Citize JAPAN Post Office Post Office Address 2-1, WAKAHAGI 4- INBA-GUN CHOME, INBAMURA City Country of Citize JAPAN City JAPAN City State or Country CHIBA CHOME, INBAMURA CHOME, INBAMURA Title of the Invention:		
Address 2-1, WAKAHAGI 4- CHOME, INBAMURA Full Name of Inventor ⁽²⁾ Residence & City CHIBA CHIBA CHOME, INBAMURA First Name SEIGO State or Foreign Country JAPAN Country of Citizer State or Foreign Country JAPAN Post Office Address 2-1, WAKAHAGI 4- CHOME, INBAMURA CHOME, INBAMURA CHOME, INBAMURA Title of the Invention: POLYMER COMPOUND, METHOD OF PRODUCING THE SAME, PHOTOSENSITIVE COMAND PATTERN FORMATION METHOD	Country of Citizenship JAPAN	
of Inventor ⁽²⁾ Residence & City Citizenship CHIBA Post Office Address Address 2-1, WAKAHAGI 4- CHOME, INBAMURA CHOME, INBAMURA CHOME, INBAMURA Title of the Invention: POLYMER COMPOUND, METHOD OF PRODUCING THE SAME, PHOTOSENSITIVE COMAND PATTERN FORMATION METHOD	State or Country Zip Code	
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Title of the Invention: POLYMER COMPOUND, METHOD OF PRODUCING THE SAME, PHOTOSENSITIVE COM AND PATTERN FORMATION METHOD	1609	
X Patent specification was filed on	POSITION,	
The state of the s		
No earlier-filed foreign applications of which priority benefit is claimed. Required information as to earlier-filed foreign applications of which priority benefit is claimed appears on page 2	attached.	
No earlier-filed U.S. applications of which priority benefit is claimed.		
Required information as to earlier-filed U.S. applications of which priority benefit is claimed appears on page 2 at	tached.	

POWER OF ATTORNEY: The power to prosecute this application and transact all business in the Patent and Trademark Office						
connected therewith is hereby granted to the following X attorney(s) agent(s):						
Name: Brian A. Gomez			Registration No.: 44,718			
Donald W. Hunt	tley		24,673			
Send correspondence and direct telephone calls to:		Brian A. Gomez Huntley & Associates 1105 North Market Street PO Box 948 Wilmington, DE 19899-0948		Tel. No. (302) 426-0610		
I further declare that all statements made herein of my own knowledge are true and that all statements made on information and belief are believed to be true; and further that these statements were made with the knowledge that willful false statements and the like so made are punishable by fine or imprisonment, or both, under Section 1001 of Title 18 of the United States Code, and that such willful false statements may jeopardize the validity of the application or any patent issuing thereon.						
Signature of Inventor(1) SHIN UTSUNOMIYA	i -	ture of Inventor(2) GO YAMADA				
Date	Date					
Required information as to earlier-filed foreign applications of which priority benefit is claimed. I hereby claim foreign priority benefits under Title 35, United States Code, §119 of any foreign application(s) for patent or inventor's certificate listed below and have also identified below any foreign application for patent or inventor's certificate having a filing date before that of the application on which priority is claimed. Country Application No. Filing Date Priority Claimed (Yes-No)						
H	ripplication 140.	Filing Date	Friority Claime	a (xes-No)		
JAPAN	2000-007728	January 1	7, 2000	Yes		
Jāpan I	2000-395738	DECEMBER	26, 2000	Yes		
Required information as to earlier-filed U.S. applications of which priority benefit is claimed.						
I hereby claim the benefit under Title 35, United States Code, §120 of any United States application(s) listed below and insofar as the subject matter of each of the claims of this application is not disclosed in the prior United States application in the manner provided by the first paragraph of Title 35, United States Code, §112. I acknowledge the duty to disclose to the Office all information known to me to be material to patentability as defined in 37 CFR §1.56, which became available between the filing date of the prior application and the national or PCT international filing date of this application.						
U.S. Application Serial N	No. U.S.	Filing Date	Status (patented, per	nding or abandoned)		